

**Notice of References Cited**Application/Control No.  
09/606,040Applicant(s)/Patent Under  
Reexamination  
SIGRIST ET AL.Examiner  
Fariba GhashghaeeArt Unit  
1656

Page 1 of 1

**U.S. PATENT DOCUMENTS**

*		Document Number	Date	Name	Classification	
		Country Code-Number-Kind Code	MM-YYYY			
	A	US-5,563,056	10-1996	Swan et al.	435	180
	B	US-5,154,808	10-1992	Miyasaka et al.	204	157.15
*	C	US-5,858,802	01-1999	Chai-Gao et al.	436	524
	D	US-				
	E	US-				
	F	US-				
	G	US-				
	H	US-				
	I	US-				
	J	US-				
	K	US-				
	L	US-				
	M	US-				

**FOREIGN PATENT DOCUMENTS**

*		Document Number	Date	Country	Name	Classification	
		Country Code-Number-Kind Code	MM-YYYY				
*	N	WO 96/31557	10-1996	WO	Jacobsen et al.	C08J	7/18
*	O	WO 91/16425	10-1991	WO	Sigrist et al.	C12N	11/06
	P						
	Q						
	R						
	S						
	T						

**NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Leonard et al. ("ToF-SIMS and XPS Study of Photoactivatable Reagents Designed for Surface Glycoengineering", Surface and Interface Analysis, 26, pp. 793-799, 1998).
	V	Chevolot et al. ("Synthesis and Characterization of a Photoactivatable Glycoaryldiazirine for Surface Glycoengineering", Bioconjugate Chem. 10, pp. 169-175, 1998).
	W	
	X	

\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.